

TQ-M4-VSP

- 於平滑面實施超細微處理之極低粗度電解銅箔(VSP箔)
Very smooth profile ED copper foil (VSP) with very low profile surface treatment.
- 銅箔於全面蝕刻後, 於PI具良好的透視度。
Very good performance for transparency and visibility of PI after etching copper foil.
- 超低粗度處理面, 非常適合於高頻高速的應用。
Possible to use high frequency application due to very low profile.

用途/Application

- 軟性電路板
/Flexible Print Board

構成/Composition



生產地點/Production Site

- 日本/Japan

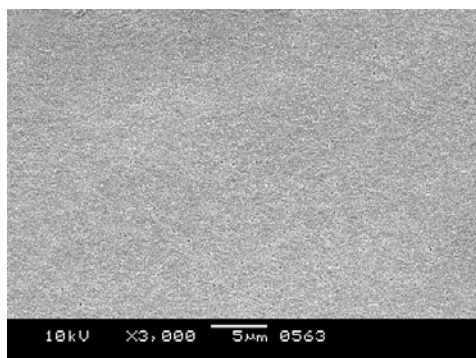
代表性特性數據/Representative

	μm	Area weight (g/m ²)	Laminate side Rz(μm)	Tensile Strength (N/mm ²)	Elongation (%)	Peel Strength (kg/cm) ^{@FR-4}
TQ-M4-VSP	12	100	0.6	340	9	0.6
	18	148	0.6	340	12	0.7

※上述表列為代表性數據非保證值

This is representative data, not guaranteed.

處理面/Laminate side



阻劑面/ resist side

